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Effect of zinc/cadmium proportion in CdS layers deposited by CBD method

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ABSTRACT

Cadmium poisoning and the cost of panel recovery which is very expensive and difficult in the buffer layers of CdS in solar cell, for these two drawbacks, we do a search on the effect of proportion of zinc/cadmium in the properties layers of CdS. For this, our studies study the properties of $Cd_xZn_{1-x}S$ layers deposited by chemical bath (CBD). CdZnS thin films were synthesized by chemical bath deposition (CBD) with different deposition protocols to optimize deposition parameters such as temperature, deposition time, ion concentrations and pH. The surface morphology, structural, optical and chemical properties of the CdZnS thin films were studied by SEM, XRD, Raman and UV-visible spectrophotometer. The transmittance is 80% in the visible region 300 nm - 800 nm; the crystalline structure is hexagonal and cubic, the grain size is between 9.95 to 25.82 nm. It is observed that the transmittance and the shape change with the concentration of zinc in the solution; this result favors the application of these films in solar cells application.

KEYWORDS: CdZnS, chemical bath, SEM, Raman, Solar Cells, Thin Films

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INTRODUCTION

The first material used in photovoltaic is silicon. But the silicon is not the ideal material for solar cells based on thin films because of their high cost of the production and low absorption coefficient. For these reasons, there are many researches on other materials in order to replace the silicon. Among these materials, the Semiconductors groups II-VI are the best candidates. The use of thin films semiconductor has generated great interest in the development of various applications in optoelectronic and electronic devices [1, 2]. The importance of technology-based thin film devices is mainly due to their low costs of production. The $Cd_xZn_{1-x}S$ is a group II-VI important semiconductor material [3, 4], $Cd_xZn_{1-x}S$ alloy compounds have great value because their energy gap can be adjusted and network parameters can be modified [5, 6, 7]. $Cd_xZn_{1-x}S$ ternaries can form a continuous series of solid solutions. CdZnS thin films were deposited by a variety of techniques, for example, Chemical Bath Deposition (CBD) [8, 9], Spray Pyrolysis [10, 11], Successive Ion Layer Adsorption and Reaction (SILAR) [12], vacuum

evaporation [13, 14], the method Dip Coating [15] and the screen printing technique [16]. Chemical deposition processes are the low-cost process. The Chemical Bath Deposition is an evolution of the process by controlled precipitation from solution. This process has recently been developed for the deposition of thin layers of the metal chalcogenide. CBD method attracts attention today because they do not require sophisticated and expensive equipment (vacuum systems): simple hot plates with a magnetic stirrer are required. In this work have been synthesized and studies the proprieties (optics, morphological and chemical composition) of CdZnS thin films obtained by Bain chemical deposition, to replace the CdS in the solar cell.

EXPERIMENTAL

The ion source materials for Cd^{2+}, Zn^{2+} and S^{2-} were used $CdCl_2$, Zn $((C_2H_3O_2)_2. 2H_2O)$ and $NH_2-CS-NH_2$, respectively. For the elaboration thin films of good quality was used the concentration of $CdCl_2$ (0.7, 0.5, 0.1M), Zn $((C_2H_3O_2)_2. 2H_2O)$ (0.3, 0.5, 0.9M) and $NH_2-CS-NH_2$ (1M), all the solutions were prepared in distilled

water, to obtain a homogeneous solution were agitated each of the elementary solutions sources for 5 minutes to obtain a thin films uniform. In a 100 ml beaker were mixed with appropriate amounts of $CdCl_2$, Zn (($C_2H_3O_2)_2.2H_2O$) and NH_2-SH-NH_2 solutions and addition of NH_4OH to adjust the pH to 12. The mixture was stirred a new to form a homogeneous solution. The glass substrates were placed vertically inside the beaker after cleaning using a standard process. The reaction temperature of bath and the time deposition were maintained at $80 \pm 5\,°C$ and 30 minutes respectively. The films were deposited with continuous stirring. To remove impurities from the surface and minimize agglomeration of the particles were made necessary cleaning of films deposited with deionized water and dried with N_2 gas. As deposited, the color of $Cd_xZn_{1-x}S$ thin films was yellow gold. During annealing, the oven vacuum used at the temperature was 500 °C for 1 hour.

Characterization

The performance of the visible light transmittance of the sample was measured using a Shimadzu UV-1800 spectrophotometer. The surface morphology of the film was observed by scanning electron microscopy (SEM) model JEOL JSM-6610LA. The crystal structure of the samples was characterized by a Bruker X-ray diffractometer with a Cu-Kα radiation wavelength (1.54 Å) and the Raman spectra were recorded with a Bruker SENTERRA R200L spectrometer.

RESULTS AND DISCUSSION

Morphological Properties

The surface of CdxZn1-xS thin films of composition x = 0.7, 0.5, 0.1, respectively, is observed by SEM is shown in Figure 1. The CdZnS layer consists of a dense layer of small crystallites and some large particles sink to the surface. These particles are most likely CdxZn1-xS colloidal particles formed on the substrate during film growth. As the composition (x) of Zn increases, is advantage incorporated into the CdS films. Which are indicated by XRD as well as SEM [17, 32]. The shape of the particle changes with increasing concentration of Zn.

### Optical Properties

The transmittance of CdZnS thin films with different concentrations is using a Spectrophotometer UV-visible (Shimadzu UV-1800). We observe that the transmittance of our samples is varied between 60 and 80% in visible region this variation due to the decrease in Zinc concentration. Whereas in the region <450 nm fundamental absorption therefore, our thin films possess transparency performance in the 450-800 nm region, the latter gives them great importance in solar cells as a buffer layer.

The optical gap energy Eg was obtained by extrapolation of the linear part of $(\alpha h\nu)^2$ on the axis of $(h\nu)$ to $\alpha = 0$, according to the following equation [18]:

$$\alpha = A\,(h\nu - Eg)^{\,n} \tag{1}$$

With A is the edge parameter and n = 1/2 for direct gap material, hν is the photon energy, Eg is the band gap. Values of optical band
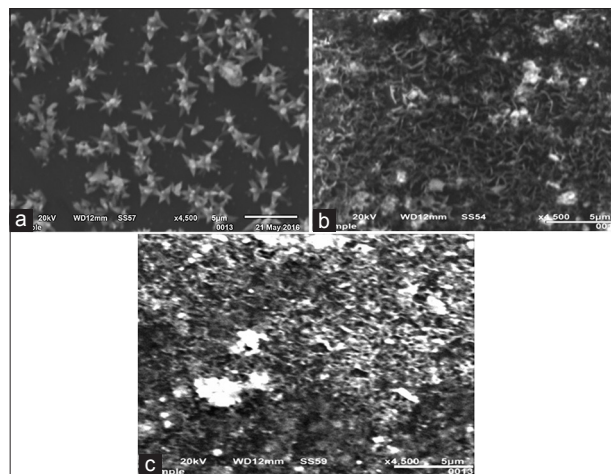
Figure 1: Typical SEM images of nanostructured $Cd_xZn_{1-x}S$ thin films (a=$Cd_{0.1}Zn_{0.9}S$, b= $Cd_{0.5}Zn_{0.5}S$, c= $Cd_{0.7}Zn_{0.3}S$) annealed at 500 °C
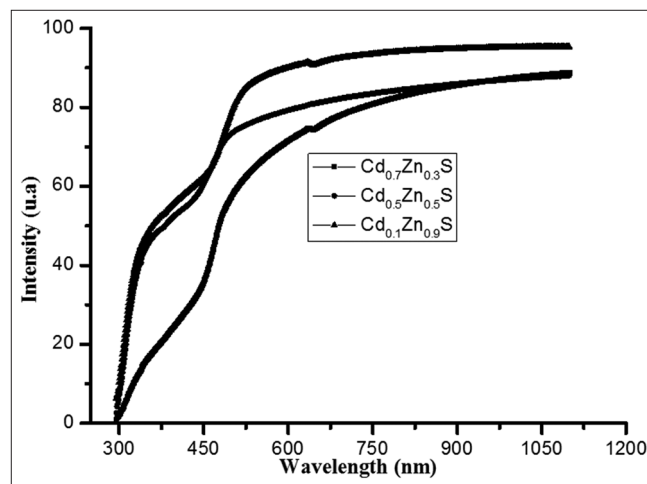
Figure 2: Transmission spectra of $Cd_xZn_{1-x}S$ thin films.

gap Eg of thin films ($Cd_{0.7}Zn_{0.3}S$, $Cd_{0.5}Zn_{0.5}S$ and $Cd_{0.1}Zn_{0.9}S$) are (3.5, 3.61 and 3.8 eV) respectively, we find that the gap energies of our thin layers are closer to that of ZnS [19, 20].

Structural Proprieties

X-ray diffraction (XRD) spectra provide information on the composition and nature of the structure of a thin film. These X-ray diffraction patterns confirm the formation of the ternary system $Cd_xZn_{1-x}S$ with x = (0.1, 0.5, 0.7) are present in Figure 4. The peaks: (100), (002), (101), (110), (103), (200) and (201) correspond to the hexagonal structure of the thin films of $Cd_{0.7}Zn_{0.3}S$ and $Cd_{0.5}Zn_{0.5}S$. The peak (002) is the most intense for $Cd_{0.7}Zn_{0.3}S$ and $Cd_{0.5}Zn_{0.5}S$. But for $Cd_{0.1}Zn_{0.9}S$, the peaks are (111), (200), (210), (211), (300), (222), (321) and (400), the most intense peak is (200), correspond to the cubic structure. For determinations the values of the interplanar distance d experimental for the different compositions of the system $Cd_xZn_{1-x}S$ was used the Bragg relation [21] taking the value θ of the peak position of the XRD diagram. d_{exp} values 200B200B were compared with $d_{(ASTM)}$ values; Both values 200B200B are in good agreement; the values 200B200B of the interplanar
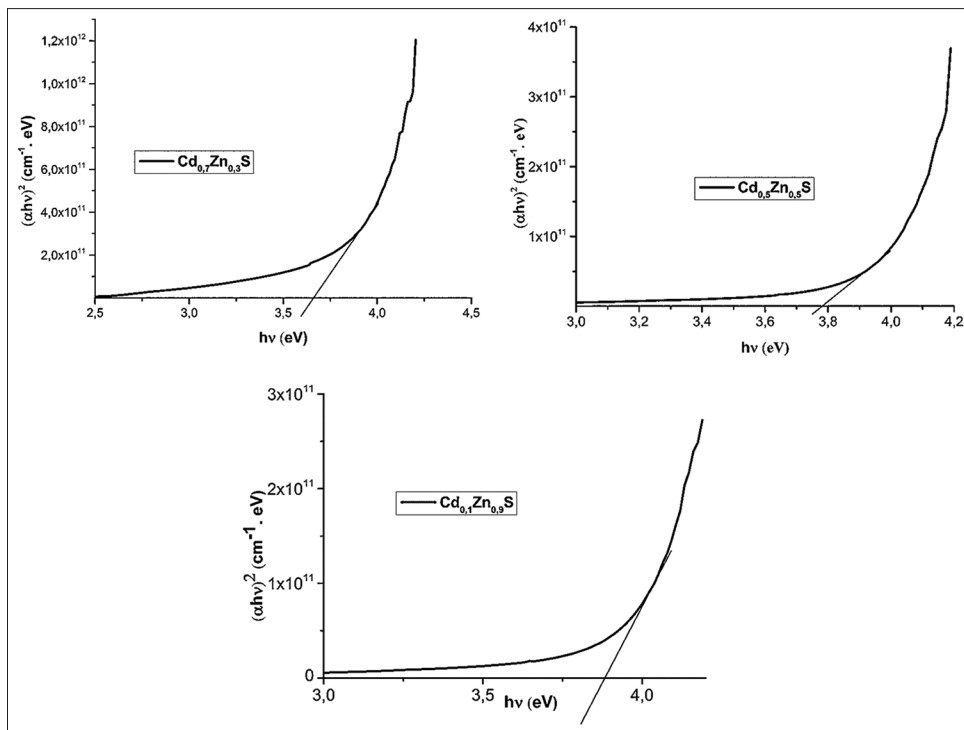
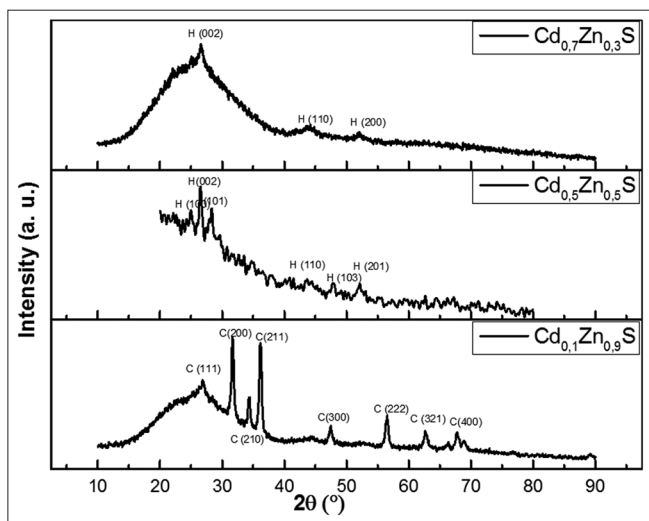**Figure 3:** Extrapolations of E$_g$ for Cd$_x$Zn$_{1-x}$S thin films

Figure 4: XRD pattern of Cd$_x$Zn$_{1-x}$S thin films

distance of the ternary alloy Cd$_x$Zn$_{1-x}$S will be linear as a function of the x concentration, as indicated in the TAB. 1. [22]

$$d = (\lambda / 2sin\theta) \qquad (2)$$

The D average size of the crystallites of CdZnS estimated according by the formula of Debye-Scherer's [23].

$$D = 0.9\lambda(\Box(2\theta)cos\theta) \qquad (3)$$

Where D is the crystallite average size, λ = 0.154 nm the mean wavelength of Cu Kα radiation and β = (Δ2θ) is the full-width half maximum (FWHM) of Bragg peak observed at Bragg angle θ (rad), K = 0.9, the values of D obtained were presented in Table 1.

The dislocation density (δ) is the number of crystallites per unit area (N) and the strain (ε) of the films are determined by relations [24].

$$\delta = 1 / D^2 \qquad (4)$$

$$\varepsilon = \beta cos\theta / 4 \qquad (5)$$

The size values of the grains, the dislocation and the deformation of the crystallites of the thin films CdxZn1-xs deposited at a temperature of 80 ± 5 ° C and annealing at 500 ° C are presented in Table 1. In the table, we see as the size of the crystallites increases with the increase of zinc compositions (x), a maximum value of the size of the crystallites corresponds to a minimum value of the deformation. On the other hand, the density of the dislocations decreased with the increase of the zinc compositions (x). CdxZn1-xS thin films with a lower dislocation and deformation density improve the stoichiometry of the films, resulting in the volumetric expansion of the thin films [8].
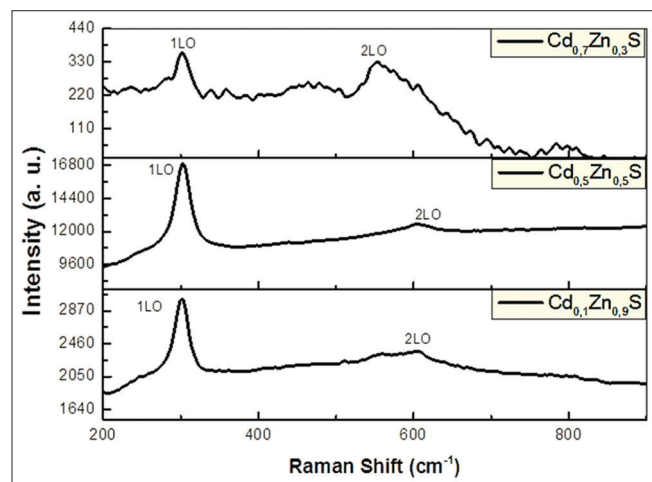
The values of the lattice parameter were calculated using the formula (6) and (7):

$$\frac{1}{d^2} = \frac{4}{3}\frac{(h^2 + hk + k^2)}{a^2} + \frac{l^2}{c^2} \qquad (6)$$

$$\frac{1}{d^2} = \frac{(h^2 + k^2 + l^2)}{a^2} \qquad (7)$$

Table 1: XRD results of CdZnS thin films

	(hkl)	d_{exp}	$d_{(ASTM)}$	D (nm)	Lattice parameter-Å	δ	ε
$Cd_{0.7}Zn_{0.3}S$	(002)	3.35	3.39	9.95	c=6.62, a=4.08	1,00 E+16	0,215
$Cd_{0.5}Zn_{0.5}S$	(002)	3.35	3.35	20.66	c=6.42, a=3.95	2,39E+15	0,103
$Cd_{0.1}Zn_{0.9}S$	(200)	2.82	2.76	25.82	a=5.73	1,50E+16	0,083

Figure 5: Raman spectra of $Cd_xZn_{1-x}S$ thin films

Moreover, the obtained values are compiled in Table 1 [25], the lattice parameter is decreased when the zinc concentration increases, when the zinc concentration is greater than 0.5 M the crystal structure changes from hexagonal to cubic.

Raman Analysis

Raman spectroscopy is one of the essential tools for the structural characterization of materials. Figure 5 shows Raman spectra at room temperature in the visible region 200 and 800 cm -1. The position of the spectral peak and the spectral width of the Raman spectra give information on the quality of the crystallinity of the film [30]. It has been noted that there are two large, well resolved asymmetric peaks corresponding to the 1LO and 2LO phonon modes in the spectrum [26, 27]. The peak position of the LO mode varies with the composition of the Zn atoms in the crystal structure CdxZn1-xS, the first peaks were observed at 301.5 cm-1, 302.5 cm-1 and 303 cm-1. Peaks of 590.4 cm-1 and 681.3 cm-1 can respectively affect the second modified harmonic of the CdZnS phonon. The existence of 1LO and 2LO phonon modes confirms the presence of a highly crystalline material. Ozer *et al*. Show that the intensity of Raman peaks changes because of the damage and disorder induced by Zn incorporation [29, 31] RS. Castillo *et al* showed that FWHM increases inversely with particle size [28]. The diffusion of Zn into the crystalline structure also resulted in a more asymmetrical line shape towards a higher energy side.

CONCLUSIONS

The CdZnS thin films are produced by the chemical bath deposition technique. The synthesis was easy to achieve on large-area glass substrates. The SEM characterization study shows that the morphology of the surface is changed depending on the concentration of zinc. The transmittance is about 60 to 80% and the energy of the range is changed from 3.5 to 3.8 eV. The crystalline structure is hexagonal for ($Cd_{0.7}Zn_{0.3}S$ and $Cd_{0.5}Zn_{0.5}S$) and cubic for $Cd_{0.1}Zn_{0.9}S$. and the grain size is between 9.95 and 25 nm.

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